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Exploration of a 2D Material Monte Carlo Simulator: Parallelization Strategy and Noise Characterization of MoS₂

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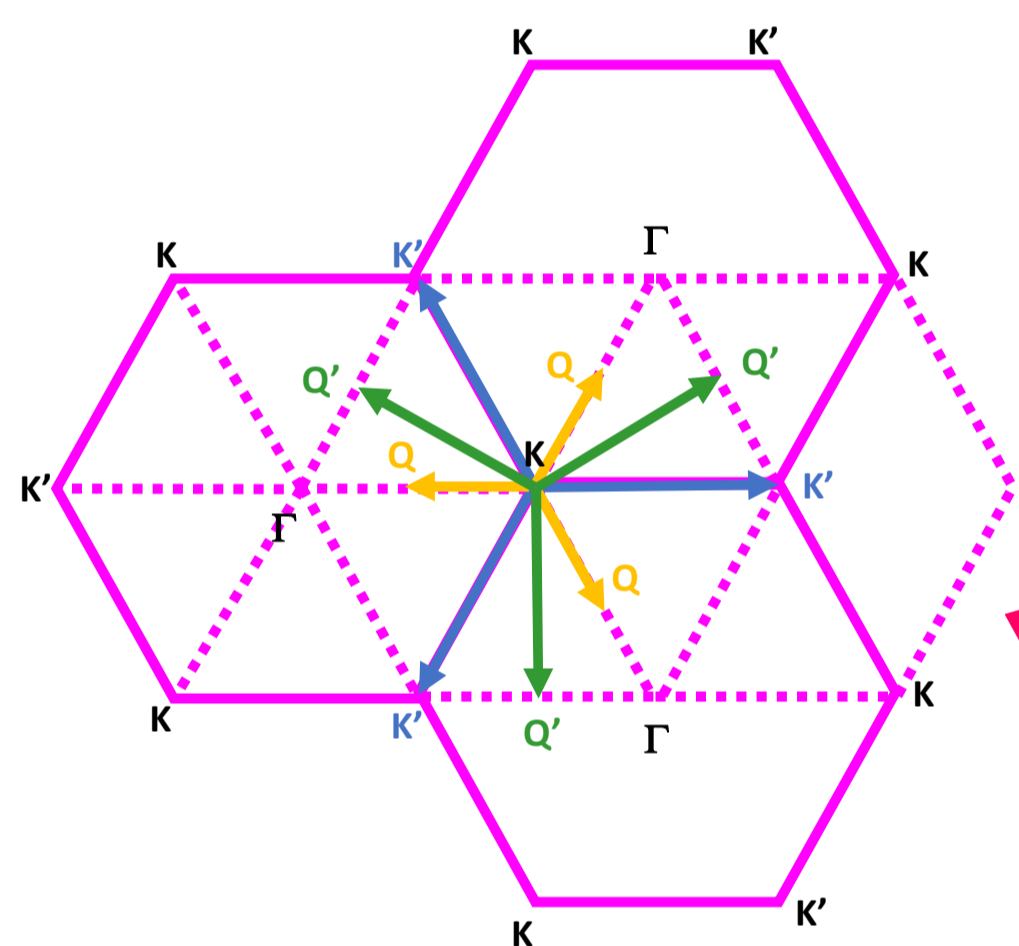
INTRODUCTION

Two dimensional (2D) metal dichalcogenides are under an intensive research which is mainly motivated by their inherent bandgap and their feasible applications beyond gapless graphene [1]. The dichalcogenides possess fascinating properties such as a direct bandgap, promising novel optical and electronic properties [2]. An exhaustive study of electronic transport of these materials is essential to assess their application by advanced physically-based models as an ensemble Monte Carlo (MC) technique which present well-recognised benefits to model the stochastic and quantum-mechanical transport processes at nanoscale.

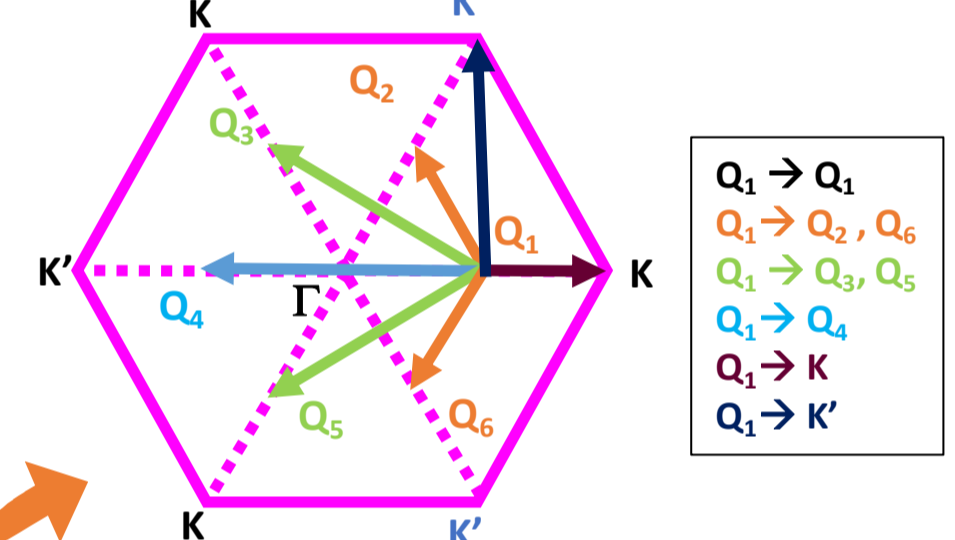
In this work, an in-house ensemble Monte Carlo (MC) simulator has been developed and widely tested for the study of different 2D materials such as graphene, silicene, molybdenum disulfide (MoS₂) and other transition metal dichalcogenides [3, 4, 5, 6]. We have focused on exploiting the advantages that this tool offers to characterize the microscopic noise sources in MoS₂ due to charge fluctuations and also in developing a parallelization strategy under Message Passage Interface (MPI) in order to upgrade our purely sequential MC simulator.

MC: Noise Characterization of MoS₂

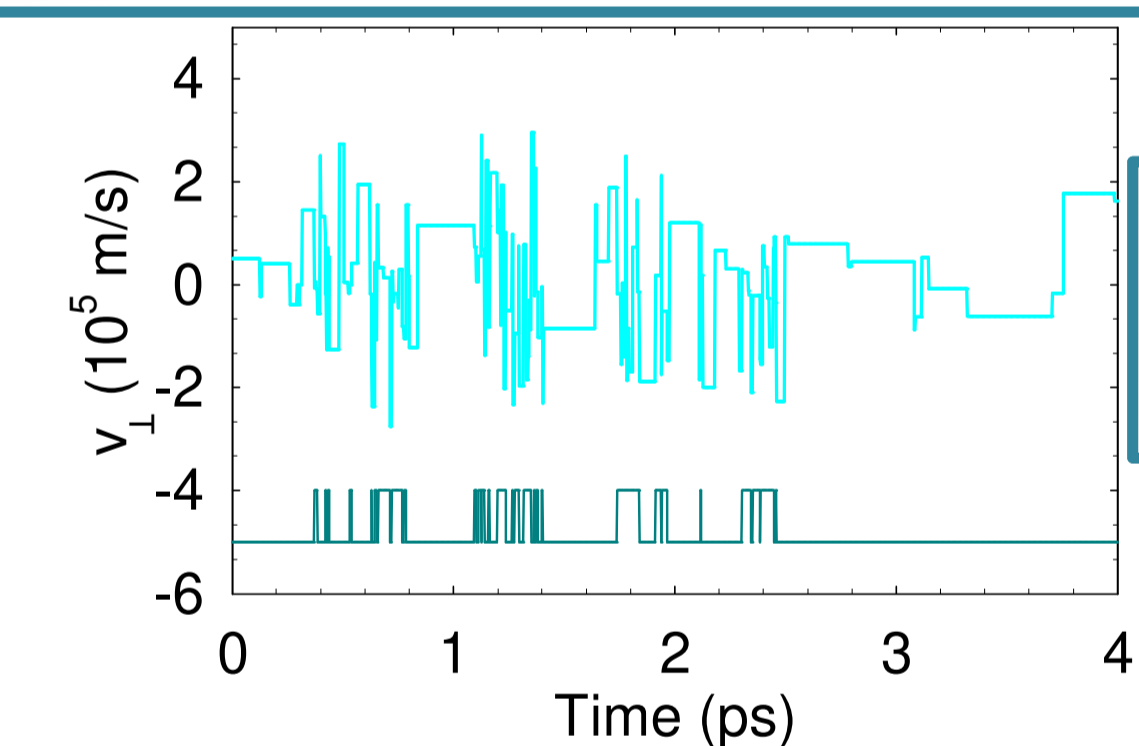
- **Non-degenerate conditions** considered (50.000 super-particles).
- Phonon branches considered [2]:
 - ✓ Intravalley acoustic phonons.
 - ✓ Intervalley acoustic phonons.
 - ✓ Optical phonons.
- Aggregated phonon modes to account for:
 - TA and LA.
 - TO(E'), LO(E') and A1 (homopolar).
- Deformation potentials for valley transitions, effective masses and K-Q valley separation are collected in [2].



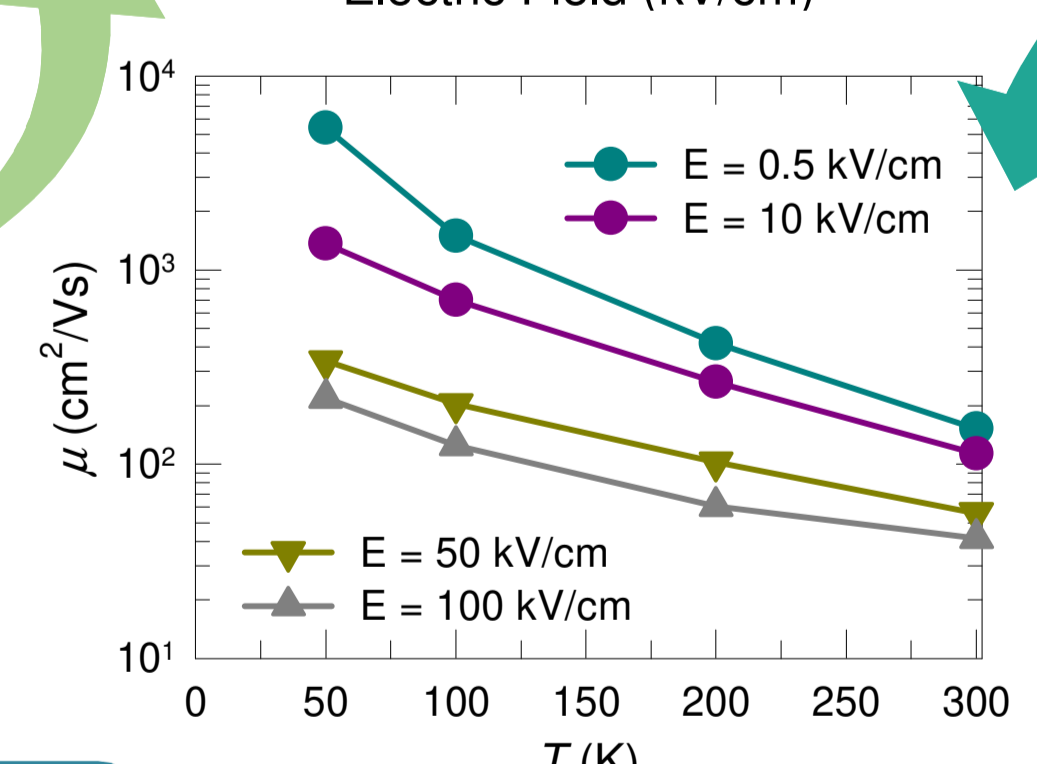
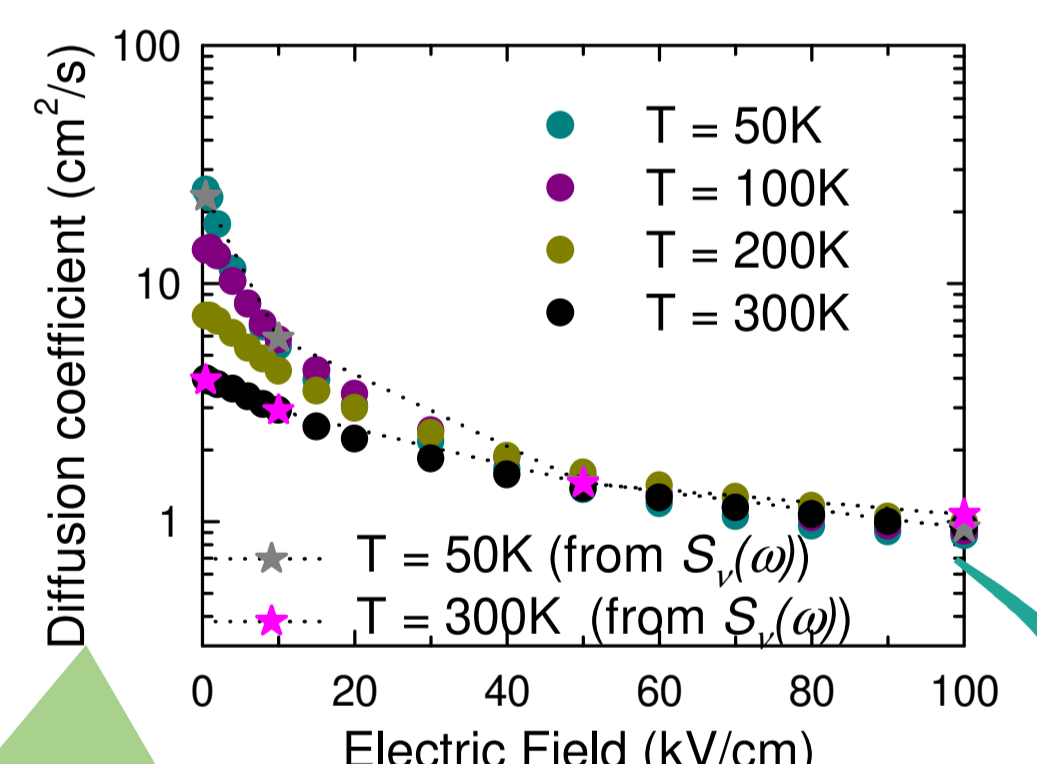
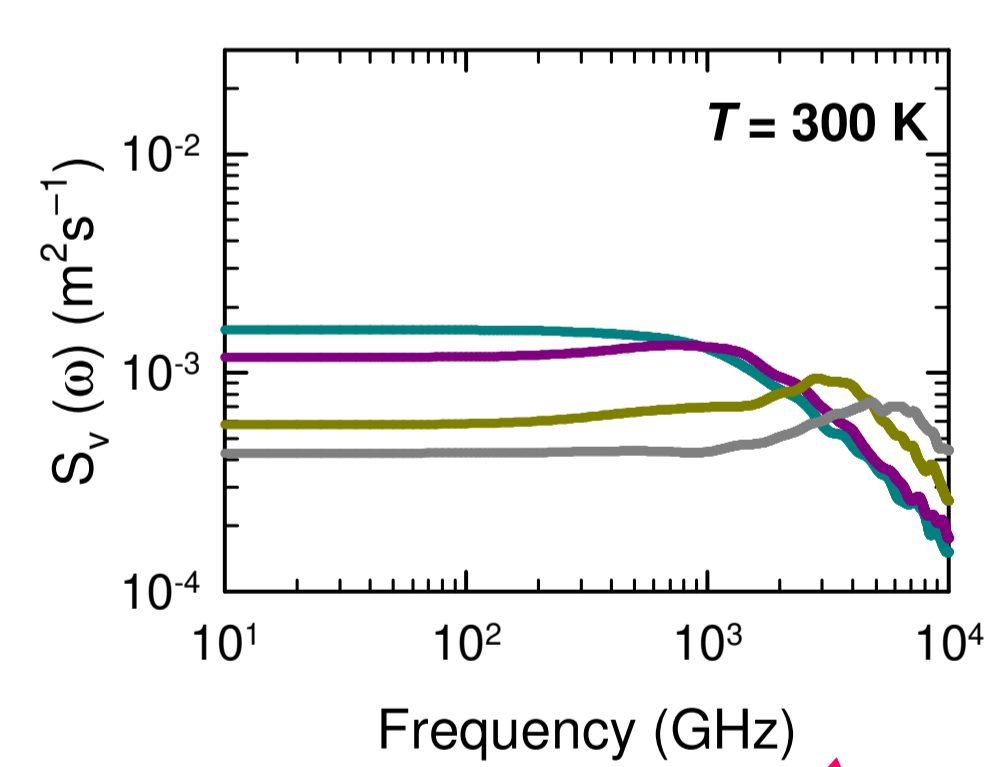
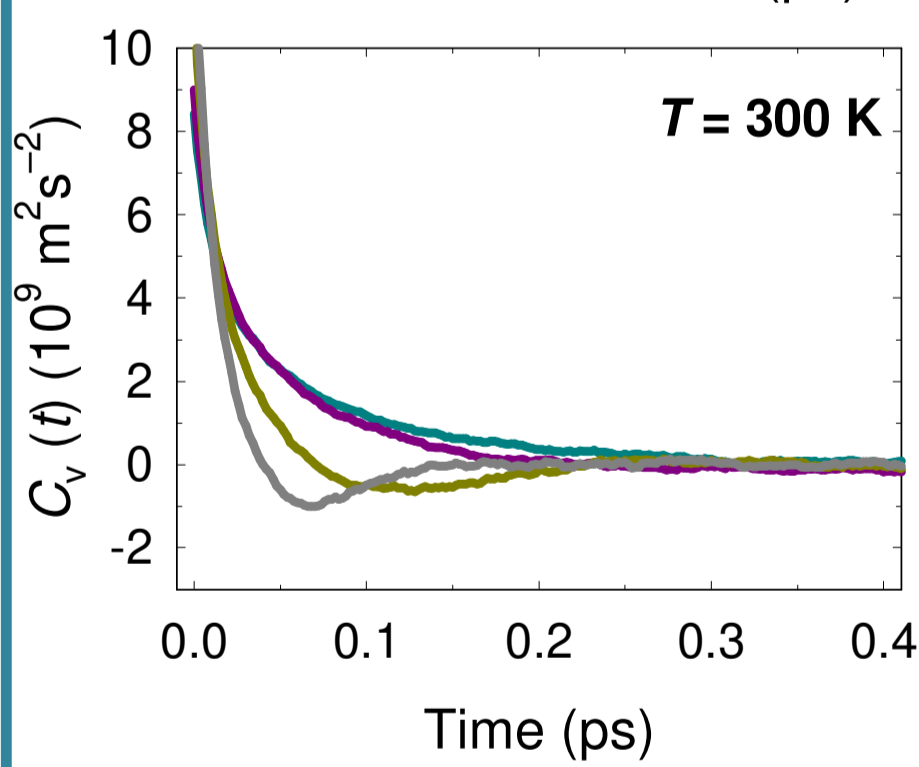
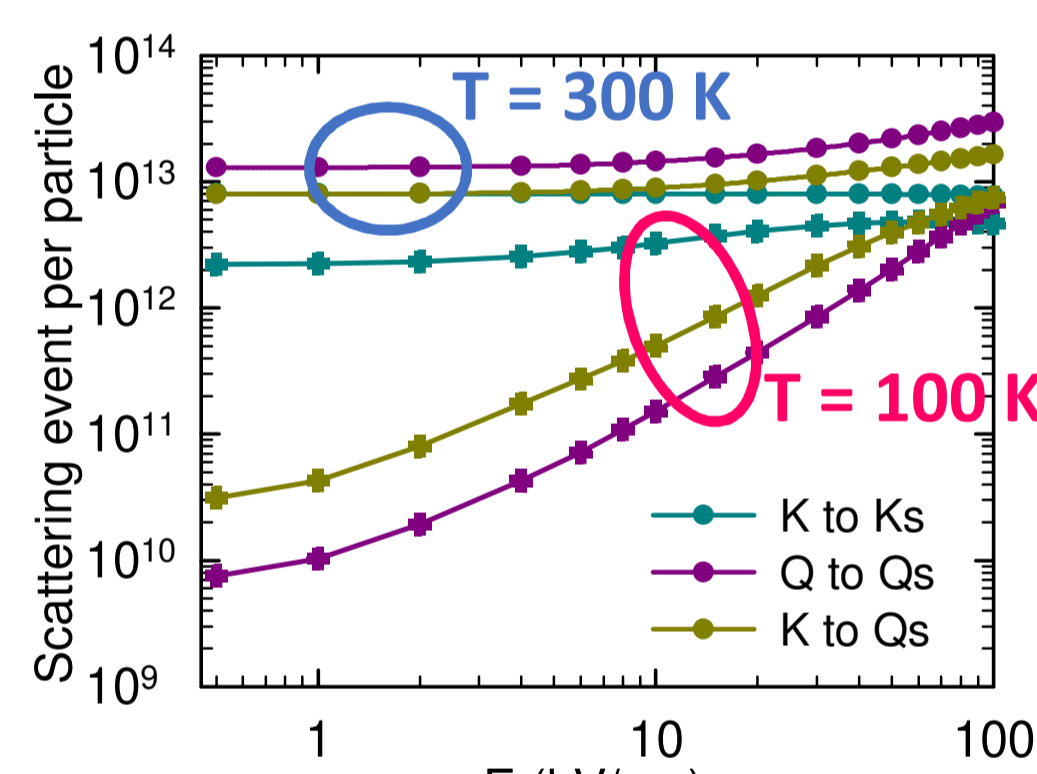
- Possible intervalley transitions for electrons:
 - in K valleys.
 - in Q valleys.



Stochastic microscopic history of a single particle:



Velocity fluctuations as the primary source of thermal noise.

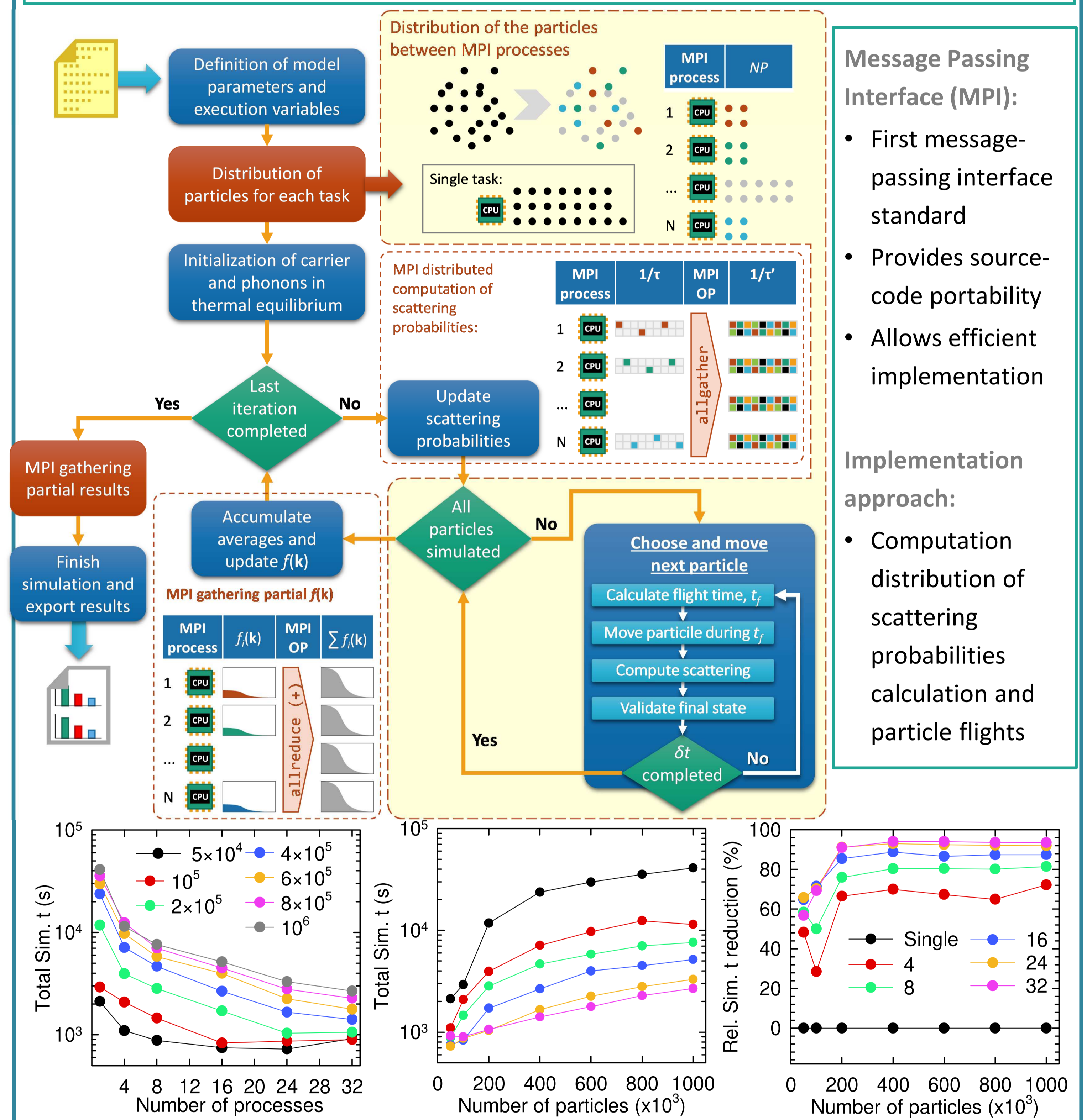


* **Correlation function** has a slow decay in a low electric field. Decay times reduce with both E and T.
→ **Spectral density** presents its maximum at larger frequencies.

* Larger decay of **diffusion coefficient** with the electric field for lower temperatures.

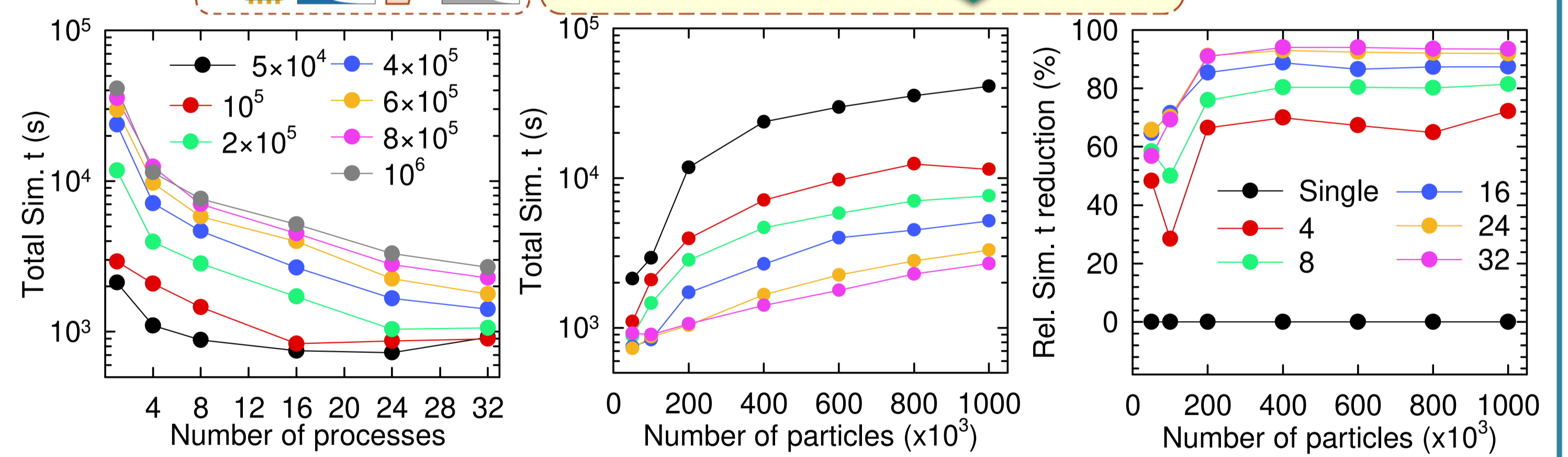
Parallelization Strategy of MC - MPI

The motion of **simulated particles** in the ensemble MC technique depends on their previous history probabilistically governed by **Boltzmann Transport Equation** using classical free flights interrupted by quantum-mechanical scattering events.



- Message Passing Interface (MPI):**
- First message-passing interface standard
 - Provides source-code portability
 - Allows efficient implementation

- Implementation approach:**
- Computation distribution of scattering probabilities calculation and particle flights



At 50.000 simulated particles, the optimum number of processes is 8 increasing the number of processes improves only slightly conditions: High relative intercommunication overhead. Simulations **with a large number of particles** decrease the relative computational burden of communications: **the best parallelization candidate**.

A greater reduction of the simulation time when passing from 1 to 4 processes, communication between them may interfere: A relative sim. time reduction of a 60% when the number of particles is larger than 200.000 for 4 processes and of 95% for 32 processes.

Conclusions

- Transfer to the upper Q valleys: important dependence on T and E.
- Diffusion coefficient is determined for the first time using a MC simulator.
- Mobilities in the range of 150 cm²/Vs to 4100 cm²/Vs at a low electric field.
- Parallelization strategy under Message Passage Interface (MPI) in our sequential MC simulator is profitable under certain conditions: a large number of particles and more complex probability simulations.
- Substantial improvements are expected with MPI in device simulations.

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